

Dr. Abdul Rahman Mohmad
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RESEARCH EXPERIENCE

- Molecular beam epitaxy (MBE) growth of various III-V semiconductors particularly GaAsBi alloys. Other materials include InGaAs, AlGaAs and GaInNAs.
- Optical and structural characterization of semiconductors using photoluminescence (PL), high resolution X-ray diffraction (HR-XRD) and atomic force microscopy (AFM).

EDUCATION

University of Sheffield, UK (2009 – 2013)

Qualification : Doctor of Philosophy in Optoelectronics

Title of thesis : Growth and Characterization of GaAsBi.

University of Sheffield, UK (2004 – 2008)

Qualification : Master of Engineering in Microelectronics

Examination Result : First Class

Achievements : First Class in all semesters. Awarded the “Hector Aitken Wainwright Prize” for academic excellence

Mara College Banting, Malaysia (2002 – 2004)

Qualification : International Baccalaureate Diploma

Examination Result : 39/45 points

EMPLOYMENT BACKGROUND

Jan 2016 – present	Post-Doctoral Associate, Department of Materials Science & Engineering, Rutgers University, New Jersey, USA
Dec 2013 – present	Research Fellow, Institute of Microengineering & Nanoelectronics, National University of Malaysia (UKM), Bangi, Malaysia
Apr 2009 – Nov 2013	PhD student, University of Sheffield, UK
Sept 2008 – Mar 2013	Junior Research Fellow, Institute of Microengineering & Nanoelectronics, National University of Malaysia (UKM), Bangi, Malaysia
June 2007 – Sept 2007	Paid internship, University of Newcastle, UK

AWARDS

2015	Ministry of Higher Education Grant for post-doctoral studies
2014	Young Researcher Grant
2011	UK Semiconductor 2011 Best Poster Award
2009	Ministry of Higher Education Scholarship for PhD

2008	Hector Aitken Wainwright Prize from University of Sheffield
2007	Summer Internship Award from University of Newcastle
2004	MARA Scholarship for undergraduate programme
2002	MARA Scholarship for International Baccalaureate Diploma

JOURNAL PUBLICATIONS

1. **A. R. Mohmad**, F. Bastiman, J. S. Ng, S. J. Sweeney and J. P. R. David, "Photoluminescence investigation of high quality GaAsBi on GaAs", Appl. Phys. Lett. **98** 122107 (2011) [*IF* = 3.302, *Q1*]
2. **A. R. Mohmad**, F. Bastiman, C. J. Hunter, J. S. Ng, S. J. Sweeney and J. P. R. David, "The effect of Bi composition to the optical quality of GaAsBi", Appl. Phys. Lett. **99** 042107 (2011) [*IF* = 3.302, *Q1*]
3. **A. R. Mohmad**, F. Bastiman, J. S. Ng, S. J. Sweeney and J. P. R. David, "Room temperature photoluminescence enhancement in GaAsBi alloys", Phys. Stat. Solidi. C **9** 259 (2012)
4. **A. R. Mohmad**, F. Bastiman, C. J. Hunter, R. D. Richards, S. J. Sweeney, J. S. Ng and J. P. R. David, "Effects of rapid thermal annealing on GaAsBi alloys", Appl. Phys. Lett. **101** 012106 (2012) [*IF* = 3.302, *Q1*]
5. F. Bastiman, **A. R. Mohmad**, J. S. Ng, S. J. Sweeney and J. P. R. David, "Non - stoichiometric GaAsBi / GaAs (100) molecular beam epitaxy growth", J. Cryst. Growth **338** 57 (2012) [*IF* = 1.698, *Q2*]
6. C. J. Hunter, F. Bastiman, **A. R. Mohmad**, R. Richards, J. S. Ng, S. J. Sweeney and J. P. R. David, "Absorption characteristics of GaAsBi/GaAs diodes in the near infra-red", IEEE Photon. Technol. Lett. **24** 2191 (2012) [*IF* = 2.11, *Q1*]
7. R. Richards, F. Bastiman, C. J. Hunter, D. F. Mendes, **A. R. Mohmad**, J. S. Roberts, J. P. R. David, "Molecular beam epitaxy growth of GaAsBi using As₂ and As₄", J. Cryst. Growth **390** 120 (2014) [*IF* = 1.698, *Q2*]
8. **A. R. Mohmad**, F. Bastiman, C. J. Hunter, R. D. Richards, S. J. Sweeney, J. S. Ng, J. P. R. David and B. Y. Majlis "Localization effects and band gap of GaAsBi alloys", Phys. Stat. Solidi B **251** 1276 (2014) [*IF* = 1.489, *Q3*]
9. **A. R. Mohmad**, F. Bastiman, C. J. Hunter, F. Harun, D. F. Reyes, D. L. Sales, D. Gonzalez, R. D. Richards, J. P. R. David and B. Y. Majlis "Bismuth concentration inhomogeneity in GaAsBi bulk and quantum well structures", Semicond. Sci. Technol. **30** 094018 (2015) [*IF* = 2.19, *Q1*]
10. R. D. Richards, C. J. Hunter, F. Bastiman, **A. R. Mohmad** and J. P. R. David "Telecommunication wavelength GaAsBi LEDs", *accepted for publication in IET Optoelectronics*

CONFERENCE AND POSTER PRESENTATIONS

1. **A. R. Mohmad**, F. Bastiman, J. S. Ng, S. Jin, S. J. Sweeney and J. P. R. David, "Photoluminescence investigation of bulk GaAsBi on GaAs", 1st International Workshop on Bismuth Containing Semiconductors, Michigan, USA, 14-16 July 2010.
2. F. Bastiman, **A. R. Mohmad**, J. S. Ng, S. Sweeney and J. P. R. David, "Growth and characterisation of GaAs_{1-x}Bi_x for Opto-electronic applications", 25th Semiconductor and Integrated Opto-Electronics Conference (SIOE), Cardiff, UK, 18-20 April 2011.
3. Z. Batool, **A. R. Mohmad**, T. J. C. Hosea, N. Hossain, K. Hild, T. Tiedje and S. J. Sweeney, "Band gap – spin-orbit splitting cross-over observed in GaBiAs/GaAs layers with high bismuth concentration", 25th Semiconductor and Integrated Opto-Electronics Conference (SIOE), Cardiff,

UK, 18-20 April 2011.

4. **A. R. Mohmad**, F. Bastiman, J. S. Ng, S. J. Sweeney and J. P. R. David, "Composition dependent photoluminescence of GaAs_{1-x}Bi_x alloys on GaAs", 38th International Symposium on Compound Semiconductors (ISCS), Berlin, Germany, 22-26 May 2011.
5. Z. Batool, K. Hild, T. J. C. Hosea, **A. R. Mohmad**, T. Tiedje, R. Butkute, V. Pacebutas, A. Krotkus and S. J. Sweeney, "Optical characterisation of GaBiAs/GaAs samples for 1.5 μ m application", UK Semiconductor 2011, Sheffield, UK, 6-7 July 2011. (Won best poster)
6. **A. R. Mohmad**, F. Bastiman, C. J. Hunter, J. S. Ng, S. J. Sweeney and J. P. R. David, "The effect of Bi composition to the optical quality of GaAs_{1-x}Bi_x alloys", 2nd International Workshop on Bismuth Containing Semiconductors, Surrey, UK, 18-20 July 2011.
7. Z. Batool, K. Hild, T. J. C. Hosea, **A. R. Mohmad**, X. Lu, T. Tiedje, R. Butkute, V. Pacebutas, A. Krotkus and S. J. Sweeney, "Resonance of band gap and spin orbit splitting in GaAsBi/GaAs alloys", 2nd International Workshop on Bismuth Containing Semiconductors, Surrey, UK, 18-20 July 2011
8. **A. R. Mohmad**, F. Bastiman, C. J. Hunter, R. D. Richards, S. J. Sweeney, J. S. Ng and J. P. R. David, "Effects of rapid thermal annealing on the optical and structural properties of GaAs_{1-x}Bi_x", Semiconductor and Integrated Opto-Electronics Conference (SIOE) 2012, Cardiff, UK, 2-4 April 2012.
9. C. J. Hunter, F. Bastiman **A. R. Mohmad**, R. D. Richards, J. S. Ng, S. J. Sweeney and J. P. R. David, "Absorption characteristics of GaAsBi/GaAs diodes in the near infra-red", Semiconductor and Integrated Opto-Electronics Conference (SIOE) 2012, Cardiff, UK, 2-4 April 2012.
10. F. Bastiman, C. J. Hunter, **A. R. Mohmad**, R. D. Richards, J. S. Ng, S. J. Sweeney and J. P. R. David, "Growth and characterisation of GaAs_{1-x}Bi_x p-i-n diodes", E-MRS Spring meeting, Strasbourg, France, 14-18 May 2012.
11. R. D. Richards, F. Bastiman, C. J. Hunter, **A. R. Mohmad**, J. S. Ng and J. P. R. David, "Effect of arsenic species on growth of GaAs_{1-x}Bi_x", UK Semiconductor 2012, Sheffield, UK, 4-5 July 2012
12. C. J. Hunter, F. Bastiman **A. R. Mohmad**, R. D. Richards, J. S. Ng, S. J. Sweeney and J. P. R. David, "Optical and electrical properties of GaAs_{1-x}Bi_x/GaAs diodes", 3rd International Workshop on Bismuth Containing Semiconductors, Victoria, Canada, 15-18 July 2012
13. **A. R. Mohmad**, F. Bastiman, C. J. Hunter, R. D. Richards, S. J. Sweeney, J. S. Ng and J. P. R. David, "The effect of growth parameters on the optical and structural quality of GaAs_{1-x}Bi_x alloys", 17th International Conference on Molecular Beam Epitaxy, Nara, Japan, 23–28 September 2012
14. R. D. Richards, F. Bastiman, **A. R. Mohmad**, C. J. Hunter, J. P. R. David, N. J. Ekins-Daukes, "GaAsBi MQWs for multi-junction Photovoltaics", 39th IEEE Photovoltaic Specialist Conference, Florida, USA, 16-21 June 2013.
15. C. J. Hunter, D. F. Reyes, D. González, F. Bastiman, **A. R. Mohmad**, R. Richards, and J. P. R. David, "TEM characterization of bulk GaAsBi layers", UK Semiconductor 2013, Sheffield, UK, 1-2 July 2013.
16. **A. R. Mohmad**, B. Y. Majlis, F. Bastiman, C. J. Hunter, R. D. Richards, J. P. R. David, "GaAsBi for photovoltaic applications", 7th IMEN UKM-PPET LIPI Joint Seminar on Nanotechnology, Microelectronic Devices, Systems and Instrumentations, Bandung Indonesia, 21-22 Nov 2013.
17. **A. R. Mohmad**, B. Y. Majlis, F. Bastiman, C. J. Hunter, R. D. Richards, J. S. Ng, J. P. R. David,

“Photoluminescence from localized states in GaAsBi epilayers”, IEEE International Conference on Semiconductor Electronics (ICSE 2014), Kuala Lumpur Malaysia, 27-29 Aug 2014.

18. R. Roberts, F. Bastiman, C. Hunter, **A. R. Mohmad**, J. Roberts, J. David, “Growth and Characterisation of GaAsBi multiple quantum well structures”, 41th International Symposium on Compound Semiconductor (ISCS 2014), Montpellier France, 11-15 May 2014
19. F. Harun, T. B. O. Rockett, **A. R. Mohmad**, R. D. Richards, Z. Zhou, F. Bastiman, J P. R. David, “Polarised Photoluminescence Study of GaAsBi Grown by Molecular Beam Epitaxy”, UK Semiconductor 2015, Sheffield UK, 1-2 July 2015
20. D. Fernandez, F. Bastiman, **A. R. Mohmad**, D. L. Sales, R. Beanland, A. M. Sanchez, J. P. R. David and D. Gonzales, “(S)TEM analysis of segregation and CuPt atomic ordering in GaAsBi/GaAs layers”, Microscopy of Semiconducting Materials (MSM-XIX), Cambridge UK, 29 Mar – 2 Apr 2015.

TEACHING RESPONSIBILITIES

1. Z1RR6012 Fundamental of Nanoelectronics
2. Z1RR6042 Micro technology and MEMS/NEMS devices

SERVICES

1. Reviewer for international journals (Applied Physics Letters) and conferences (RSM2013, ICSE2014)
2. Technical Program Chair for Topical Meeting on Photonics (TMP2015) in UKM, Malaysia

REFEREES

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